

April 15, 2004

To: Commissioner for Patents

P.O.Box 1450

Alexandria, VA 22313-1450

Fr: George O. Saile, Reg. No. 19,572

28 Davis Avenue

Poughkeepsie, N.Y. 12603

Subject:

ί

Serial No. 10/772,938 02/05/04

Chii-Ming Wu et al.

METHOD OF FORMING METAL SILICIDE

## INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO-1449, Information Disclosure Citation In An Application.

The following Patents and/or Publications are submitted to comply with the duty of disclosure under CFR 1.97-1.99 and 37 CFR 1.56.

## CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on April &, 2004.

Stephen B. Ackerman, Reg.# 37761

Signature/Date

₹.

- U.S. Patent 6,468,901 to Maa et al., "Nickel Silicide
  Including Iridium for Use in Ultra-Shallow Junctions with High
  Thermal Stability and Method of Manufacturing the Same,"
  discloses an integrated circuit device, and a method of
  manufacturing the same, including nickel silicide on a silicon
  substrate fabricated with an iridium interlayer.
- U.S. Patent 6,346,477 to Kaloyeros et al., "Method of Interlayer Mediated Epitaxy of Cobalt Silicide from Low Temperature Chemical Vapor Deposition of Cobalt," discusses a process for the preparation of cobalt disilicide films.
- U.S. Patent 6,511,867 to Lowrey et al., "Utilizing Atomic Layer Deposition for Programmable Device," discloses an apparatus that sets and reprograms the state of programmable devices.
- U.S. Patent 6,423,619 to Grant et al., "Transistor Metal Gate Structure that Minimizes Non-Planarity Effects and Method of Formation," discloses a metal gate structure formed by depositing a gate dielectric, a gate electrode, a stop layer, and a metal layer within a gate trench and removing the portions of the layers that lie outside the gate trench.

Sincerely,

Stephen B. Ackerman, Reg. #37761

Form PTO-1	41	<u> </u>								Doctor( Numb	er (Coticne)	M	Hesson Humber		<del></del>
				XI I	חוכ	ים:	$\wedge$	כווםב ש	TAMPA LE	TSM	c-03-4		1	193	8
ווארטו	٦M،	41 ብ.	1 V	N N	UIC Q Q	)  P	U_ 11	SUNCE		Chimeni	instead Chii - Ming blue of al				
:									APR 2 9 2004	Hop Dan	1 -1	1 10	mo ru run		<del>~</del>
<del>-</del>	(U)	10 5	0707	M S	NOU!	3 11 11	100	133m\l		3	02/05/	04		·	
ЕХАЧИЕЛ							Ţ		EN THE PROPERTY	ENT DO	CUMENTS	<u> </u>			
MUM	ססכטיינאל ואיייזיניו						_	סגזנ		KULE	wite .		MRCCTT	ት የሴልህ ህርአተ	JITAMOI O DYLE
	6	4	6	8	9	2 1	<u> </u>	10/22/02	Maa	eta	( .	438	655	5/2	101
	6	3	4	6	4	2 3	7/	عارعاه	Kalou	eros	et al.	438	680	1/9	101
	6	5	l	Ŀ	8	6	2	1/28/03	Low	reu e	tal.	438	128	6/3	0/01
į .	1	1	1		1 1			1/23/02	6 - +		1	438	589	,,/2	1
				<u> </u>	٩		-	114 3100	Grand	e	<u> </u>	730	201	_11/-2	30/01
<u> </u>	-	$\vdash$	$\left  \cdot \right $	-	-	- -	- -		· · · · · · · · · · · · · · · · · · ·						
		-		_	-	- -	-	·	· · · · · · · · · · · · · · · · · · ·	<del></del>					
,		_		_	_ .	_ _	_ -								
		_		_		_ _	_ _	·							
								,						·	
		-		_		- -	- -							<del> </del>	<del></del>
	i	ــــــــــــــــــــــــــــــــــــــ	<u>!</u> ]	<b></b> .	Ш		_!_	F	OREIGN P	ATENT D	OCUMENTS	<u> </u>	1	<u> </u>	
	000	OCCUMENT HUMBER					Τ	CUTE	<del></del>	אַדאַעס			SUBCLASS	Yrinil	utlen
		7	7-7-7-			+							YES	1 100	
			$\downarrow$	_	_ _	 -	_			<del></del>		· 			ļ
		_								i		·			
·									,						
	_				1	- -	1								1
		-		-	- -	- -	- -								<del> </del>
	لـــا		Ш						THED DO	CHRENT	S (Induding Au	Ime Dila C	la Parlacci	Papas 6:	1
									JINER UU	COMENT	O LINGUIST AU	uxor, 1100, U		1903, 11	·./
								<del>-</del>				••			
<u></u>								·	<del></del>						
		_						···-			· · · · · · · · · · · · · · · · · · ·				
		<del> </del>													
		-						<del></del>		·	· · · · · · · · · · · · · · · · · · ·				
										····					<del></del>
DXXXIINER										DYLE COH	«DERED .				
												•	,		
				_				<del></del>		<del> </del>					